Se	arch	Noteș	

Application/Control No.	Applicant(s)/Paten Reexamination	t under
10/788,413	ANDERSON ET A	AL.
Examiner	Art Unit	
Shengjun Wang	1617	

SEARCHED			
Class	Subclass	Date	Examiner
424	400, 489	9/14/2007	SW
514	389	9/14/2007	sw
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INTERFERENCE SEARCHED			
Class	Subclass	Date	Examiner
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SEARCH NOT (INCLUDING SEARCH)
	DATE	EXMR
CAPLUS, MEDLINE, BIOSIS EMBASE	9/14/2007	SW
DANTROLENE, particle, nanoparticle, suspention, injection, solution		
parent application	9/14/2007	
inventor search	9/14/2007	